

# spintec Spintronics in two-dimensional electron gas at metal-SrTiO<sub>3</sub> interfaces with various crystal orientations

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## Formation of 2DEG

2DEG formation by Al deposition on top of STO(001) at room temperature.

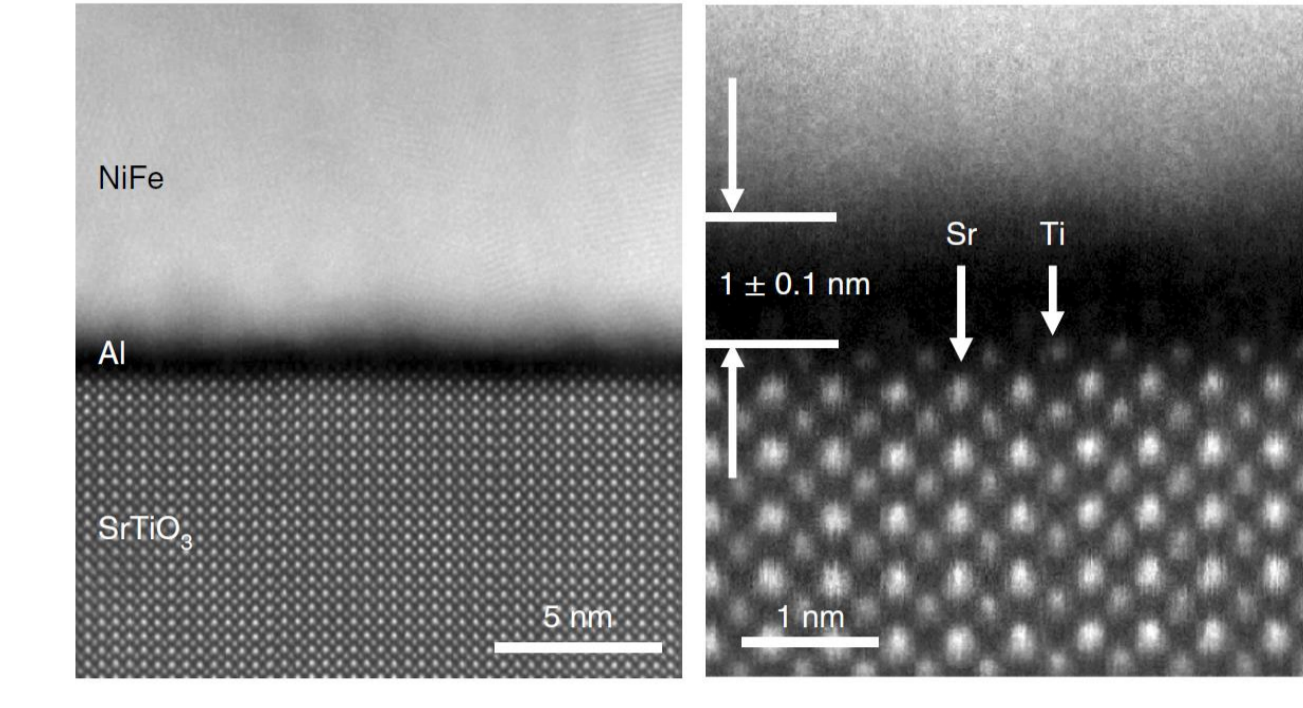
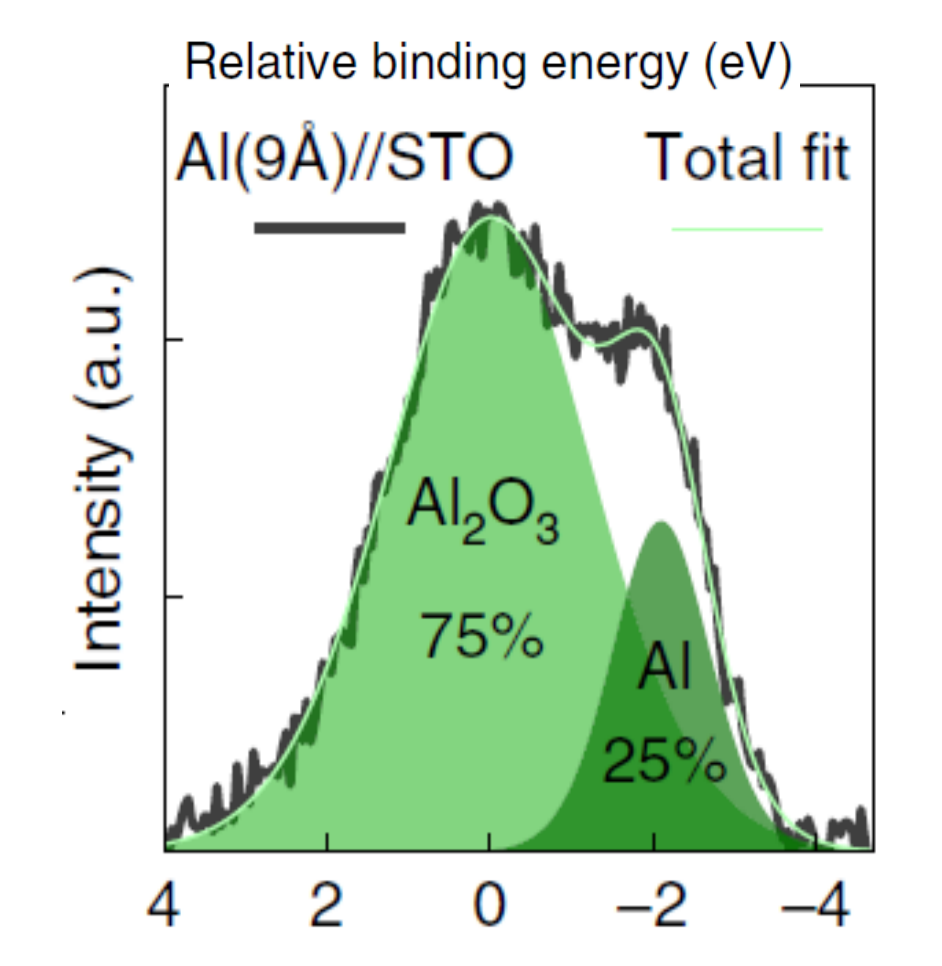
Rödel, T.C. et al., *Phys. Rev. Applied* 1, 051002 (2014)

XPS peaks show the reduction of Al at interface, with consequent creation of oxygen vacancies.

Vaz, D.C., Noël, P., Johansson, A. et al., *Nat. Mater.* 18, 1187–1193 (2019)

More generally, reactive metals induce STO reduction and 2DEG formation

Vicente-Arche et al., *Phys. Rev. Lett* 5, 064005 (2021)

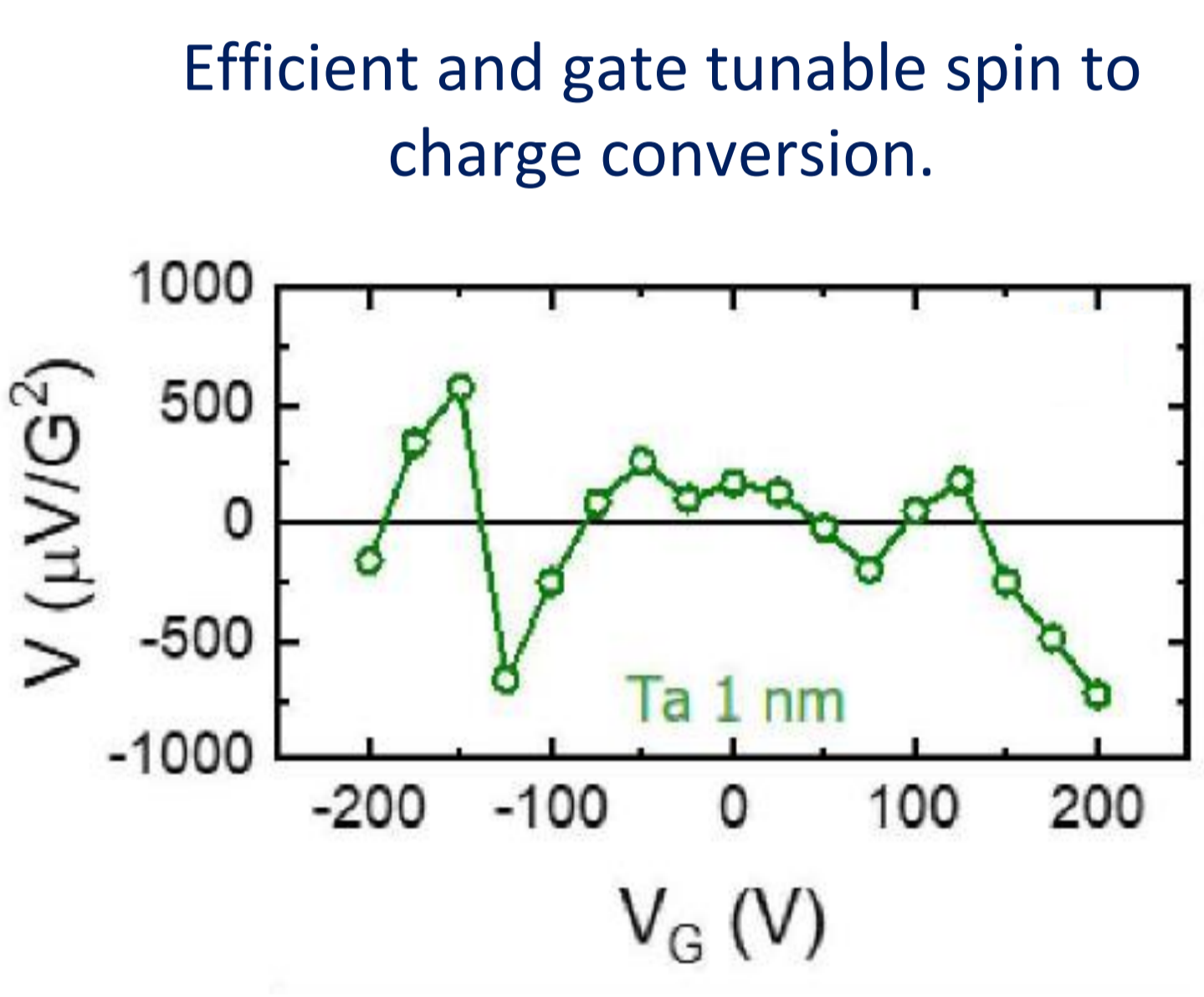
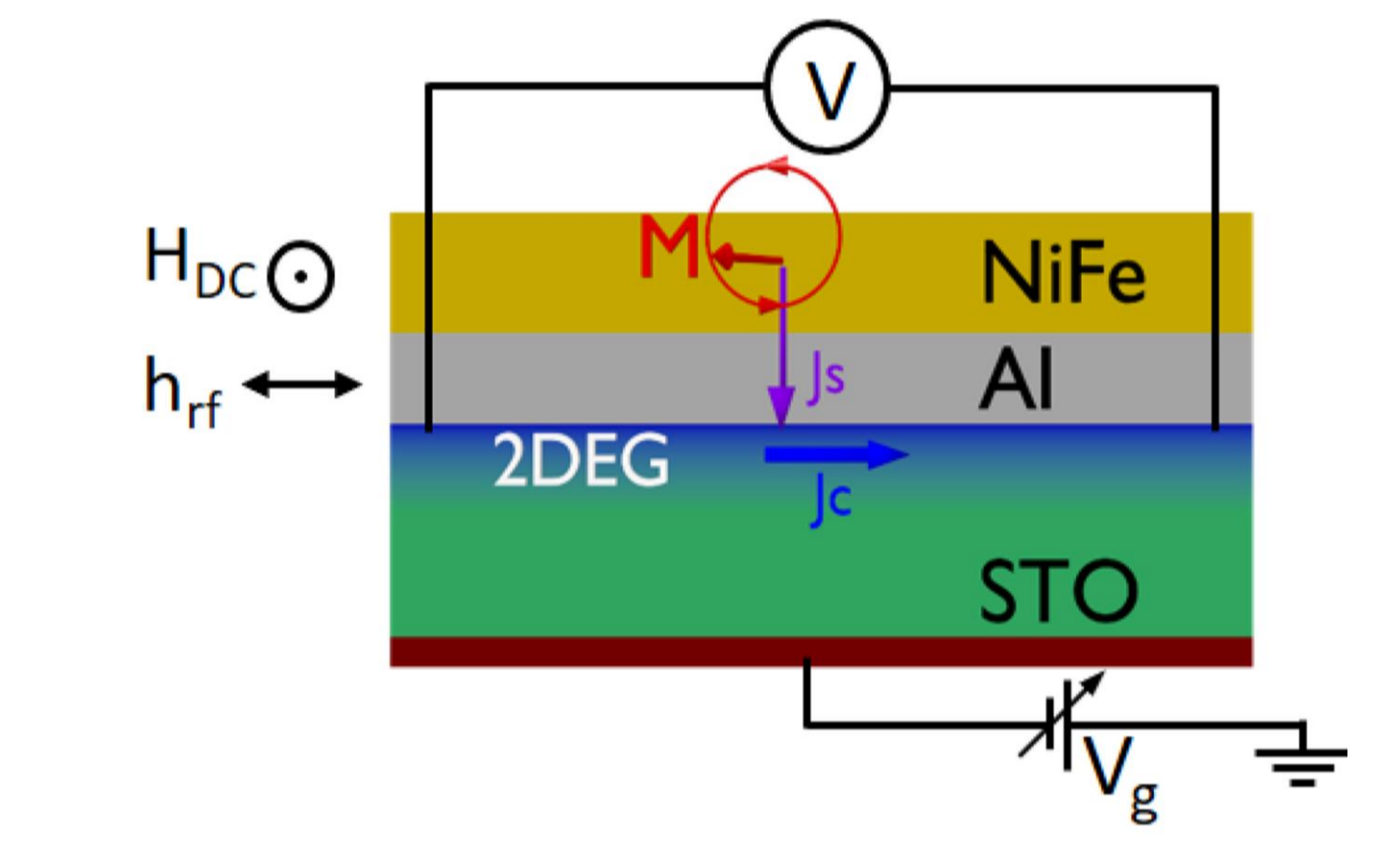


STEM images:  
 ❖ Ti terminations  
 ❖ Al barrier  
 ❖ NiFe for spin injection

## ABSTRACT

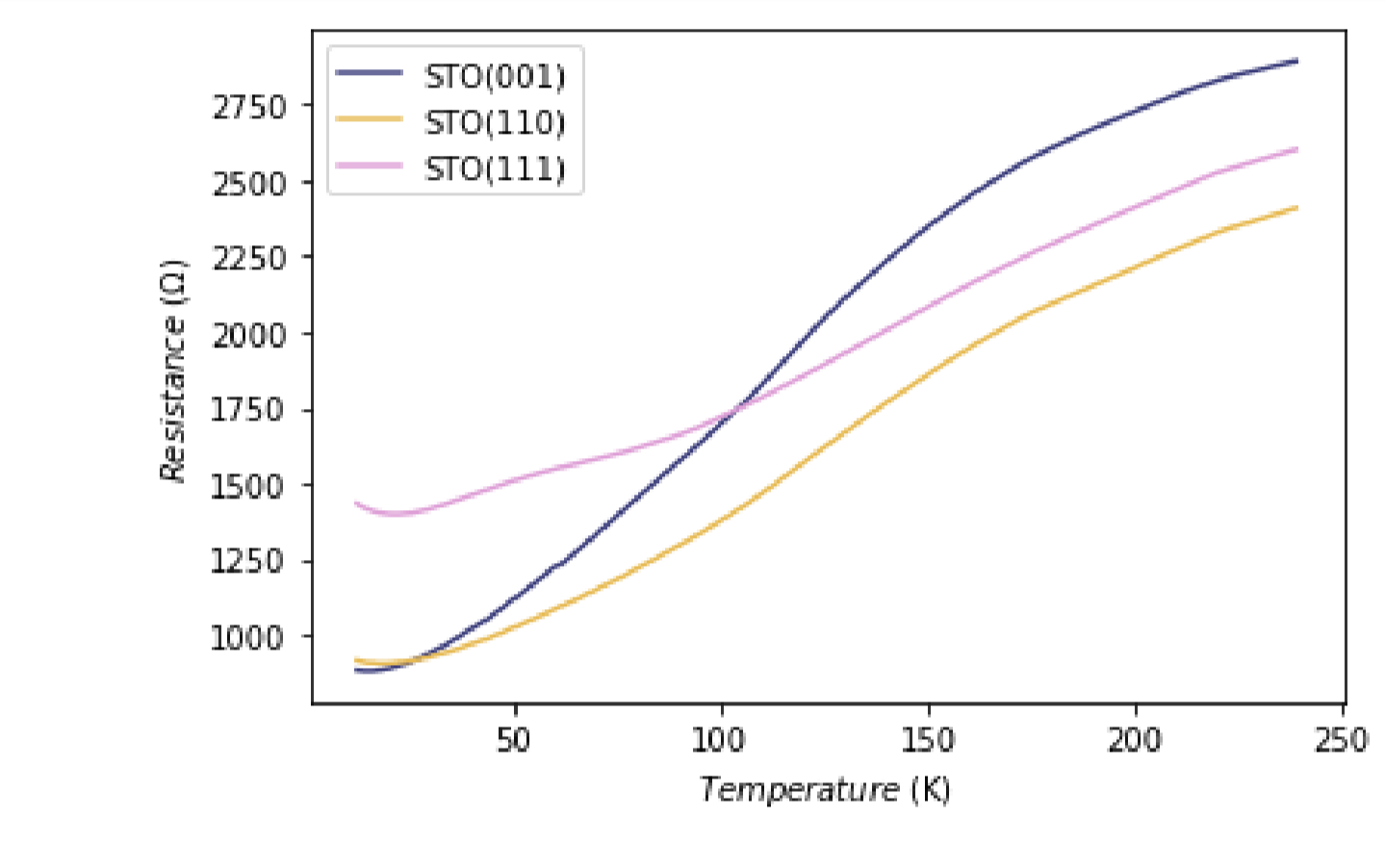
- High carrier density and gate-tunable two dimensional electron gases (2DEG) are obtained by depositing Ta on top of SrTiO<sub>3</sub> (STO with different orientations)
- 2DEG characterization: temperature dependent measurement and gate dependent magnetoresistance
- Through spin pumping, we inject a spin current from a Permalloy film into the 2DEG on top of STO(110) and detect the resulting charge current.

## Interconversion measurement in STO(001)

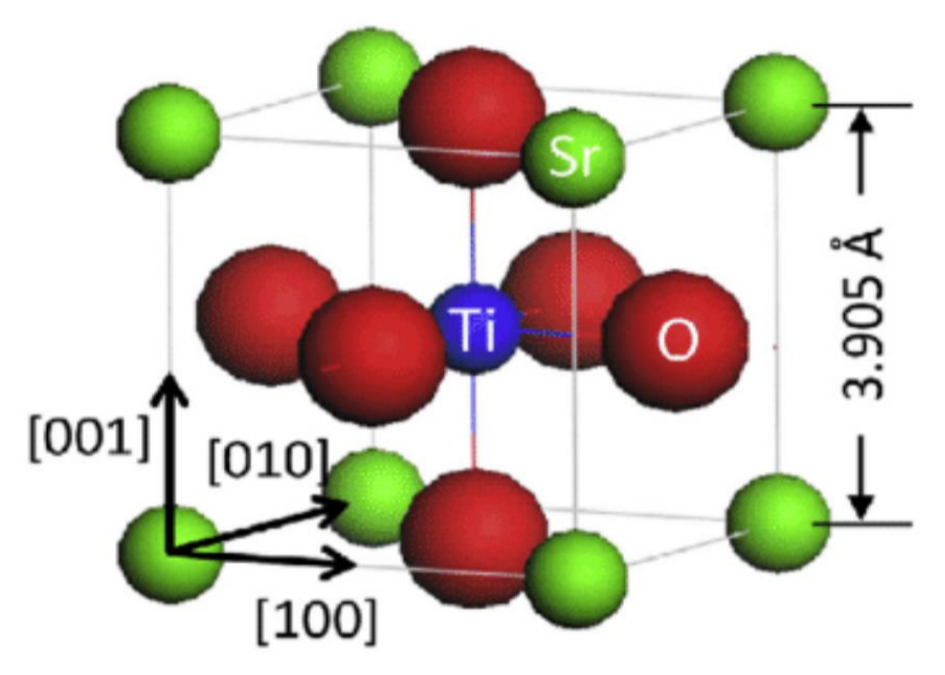


Vicente-Arche et al., *Phys. Rev. Lett* 5, 064005 (2021)

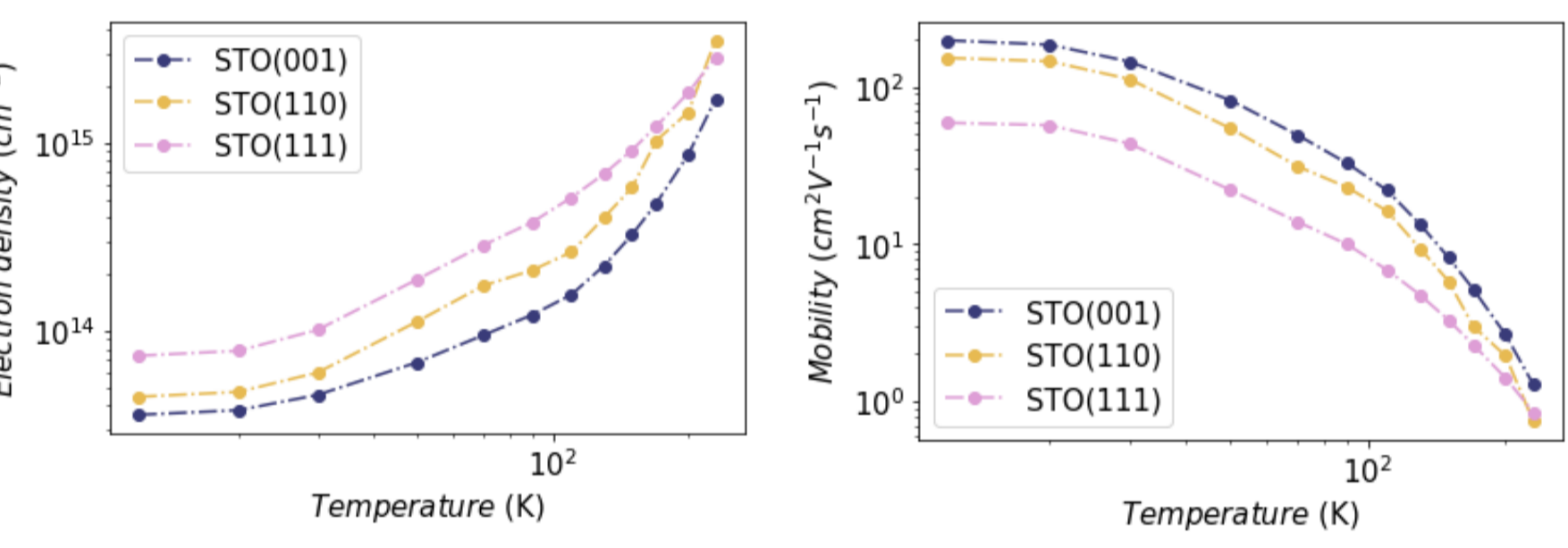
## 2DEG in STO(001), (111), (110)



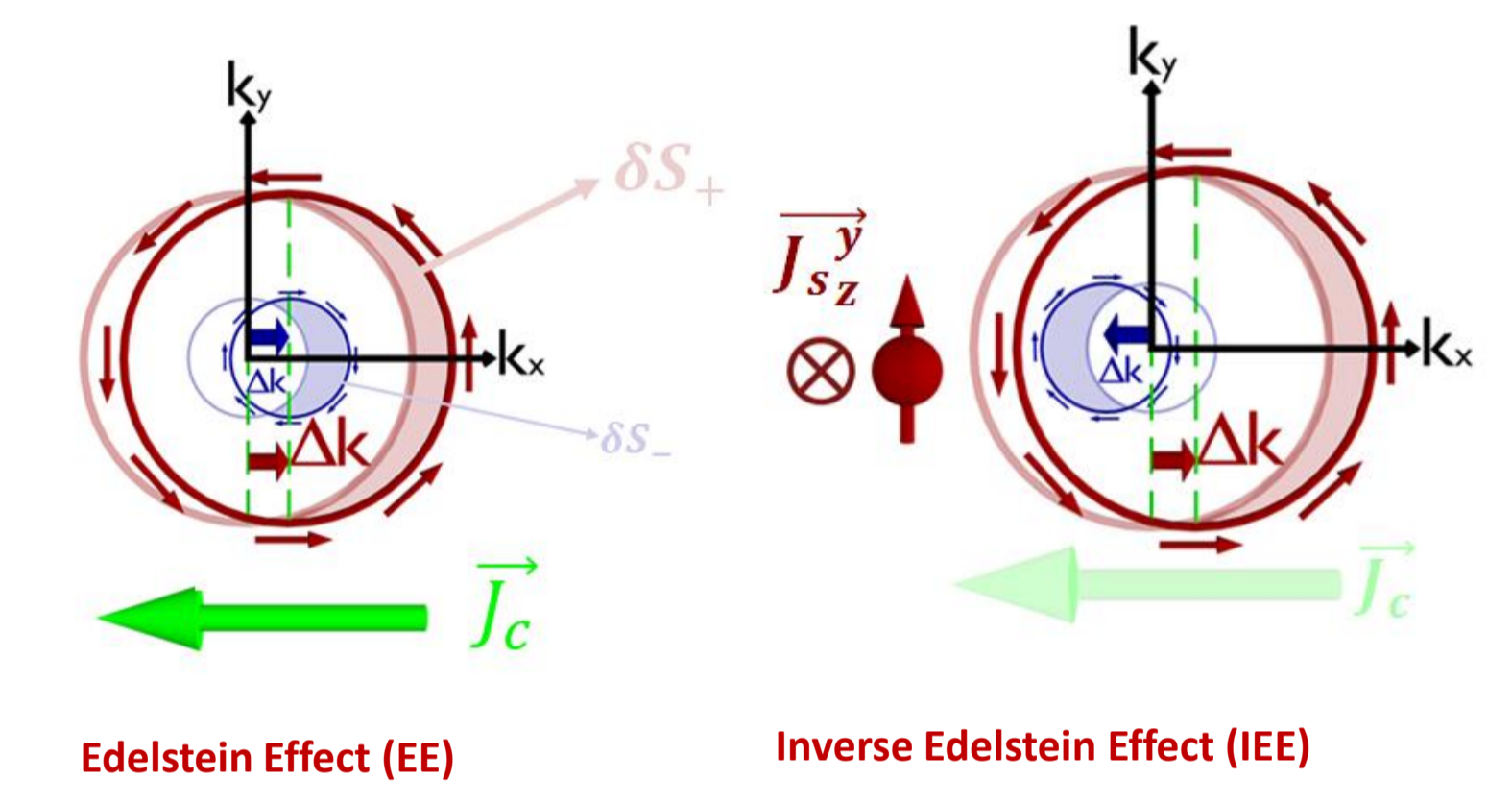
Electron gas formation along the three orientations, electron density observed is  $\sim 10^{14} \text{ cm}^{-2}$



Chang, Y., & Phark, S.H. (2017). *Current Applied Physics*, 17, 640.



## Principle of Edelstein Effect



The figure of merit is the **inverse Edelstein length**:

$$\lambda_{IEE}(m) = \frac{J_c^D(A/m)}{J_s(A/m^2)} = \frac{\alpha_R \tau}{\hbar}$$

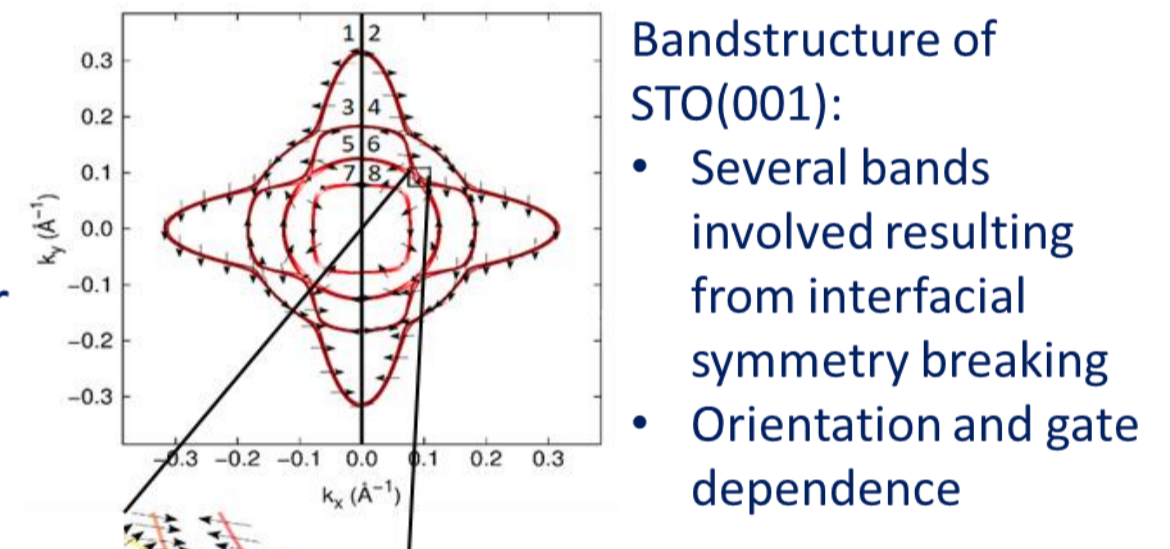
Depends on:  
 ➤ spin-orbit coupling strength  
 ➤ mobility

Spin-orbit coupling of an electron in motion under application of an electric field (along  $\hat{z}$ ):

$$\mathcal{H}_R = \alpha_R(\sigma \times p) \cdot \hat{z}$$

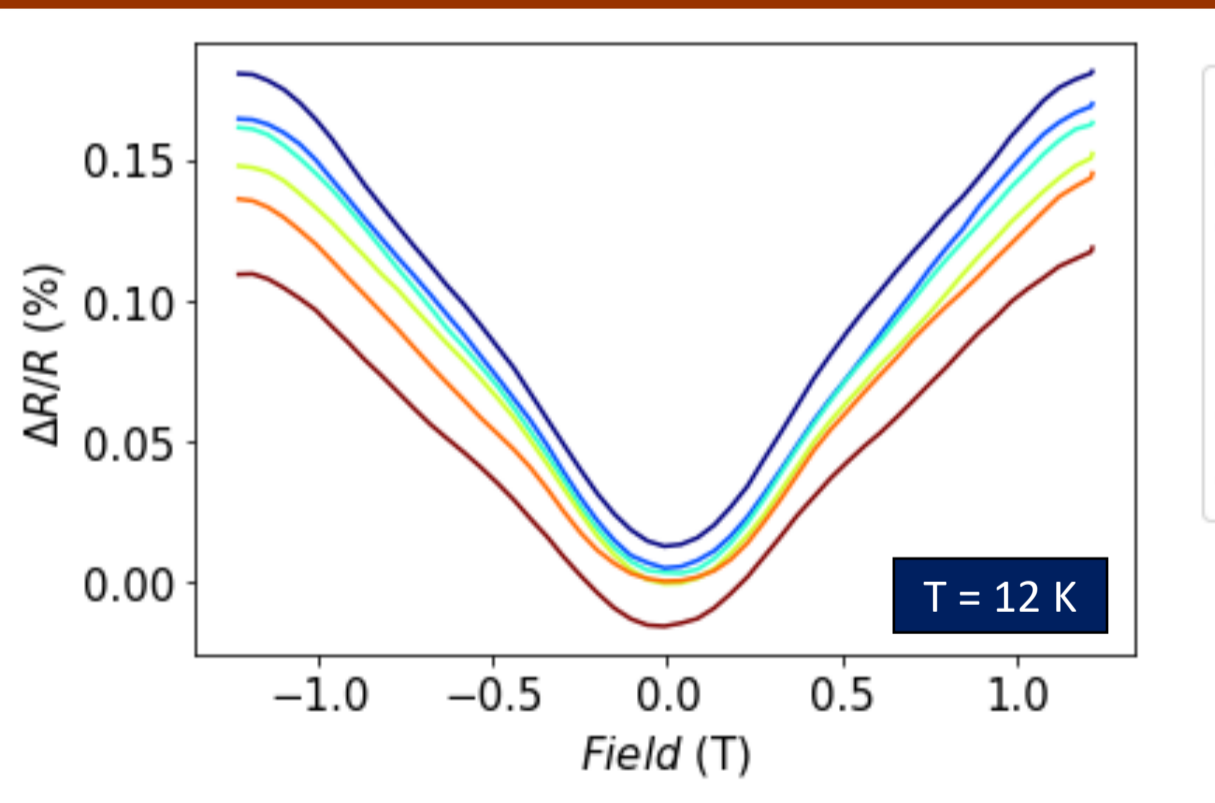
**spin-momentum locking**

If a spin-polarized current is injected, the uncompensated spin-texture generates a charge current (**IEE**).

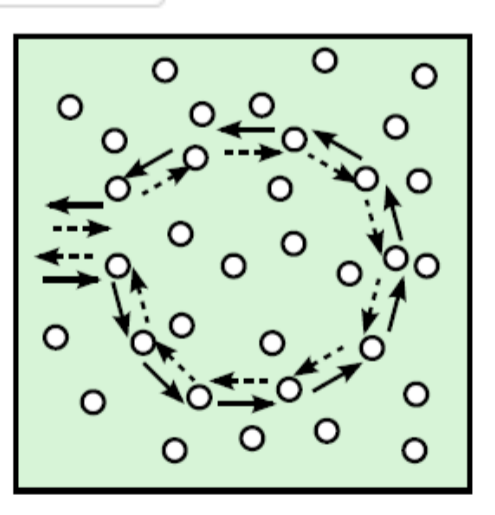


Vaz, D.C., Noël, P., Johansson, A. et al., *Nat. Mater.* 18, 1187–1193 (2019)

## Gate measurements and WAL

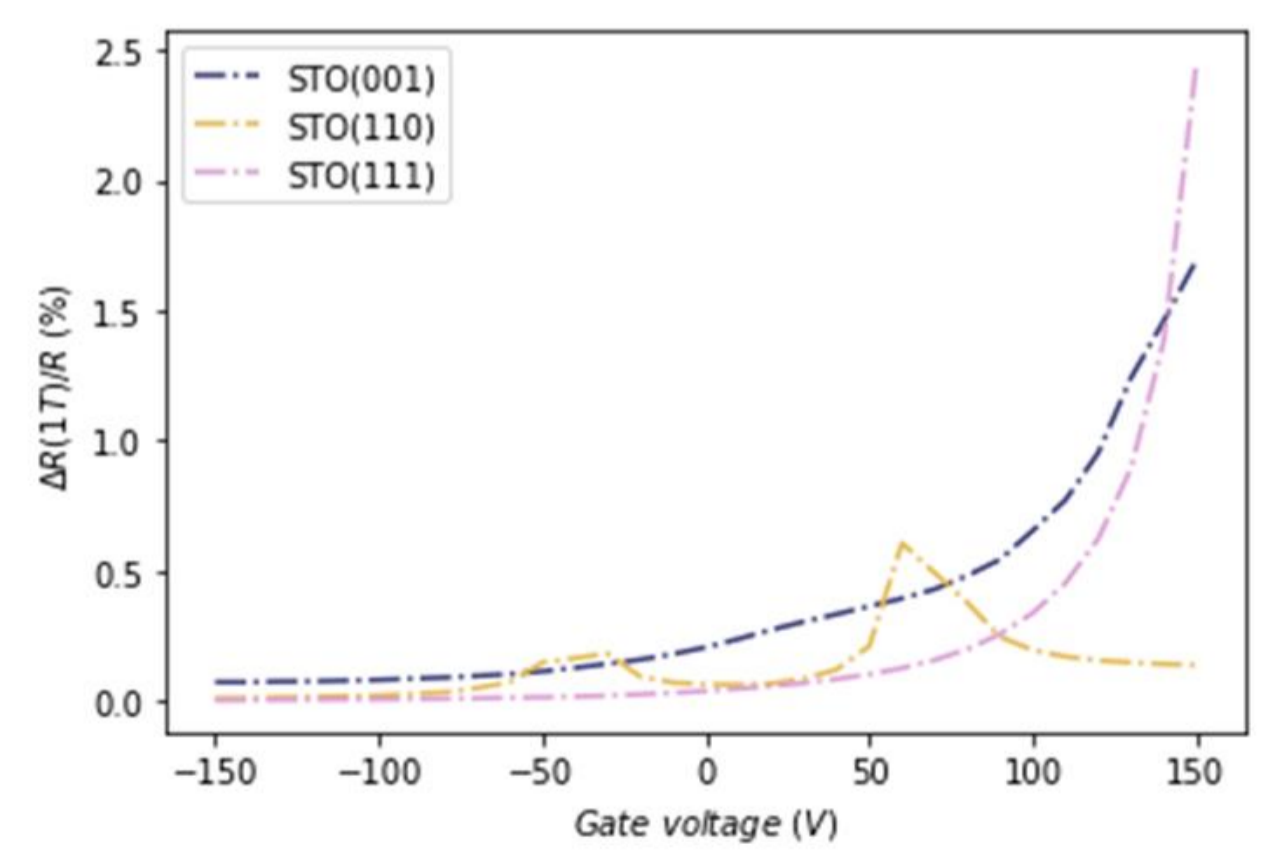


Hall measurement on STO(111) show a non-negligible symmetrical part.  
 ➤ Weak antilocalization (WAL)  
 ➤ Signature of a strong spin-orbit coupling.



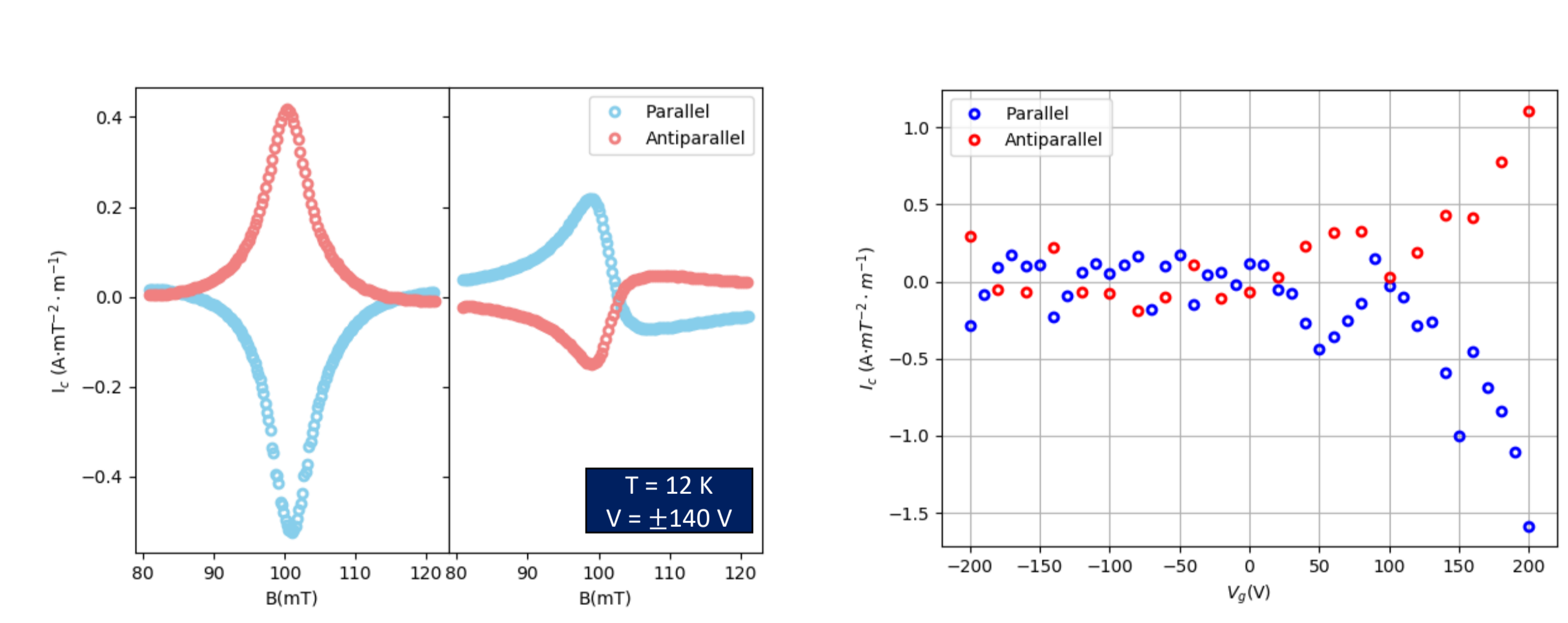
Caviglia, A. D., et al. *Phys. Rev. Lett.* 104.12 (2010): 126803.

Lu, Hai-Zhou, and Shun-Qing Shen. *Spintronics VII*. Vol. 9167. Int. Soc. for Opt. and Phot., 2014.



Gate modulated magnetoresistance:  
 ➤ Fermi level evolution for the three band structure orientations  
 ➤ Strength of spin-orbit coupling along the three directions

## Interconversion measurement in STO(111)



- Presence of efficient spin to charge conversion in STO(110)
- Different gate modulation with respect to STO(001) seen before
- Possibility to track the Fermi level position

## CONCLUSIONS

- A 2DEG can be formed at the surface of STO(001),(111),(110) by metal deposition
- Measurement by SP-FMR on (110) and (001) show a good interconversion efficiency and gate tunability
- The observation of WAL on STO(111) may be the indication of a stronger spin-orbit coupling
- Complete interconversion measurement with STO(111)
- Analysis of gate dependent interconversion in terms of Fermi level evolution on the different band structures
- Characterization and interconversion study of STO/Mg

## PROSPECTS